

GLASS FOR INFORMATION RECORDING MEDIUM SUBSTRATE, GLASS
SUBSTRATE FOR INFORMATION RECORDING MEDIUM AND MAGNETIC DISK

The present invention relates to glass to be used for an information recording
5 medium substrate such as a magnetic disk (hard disk), a glass substrate for an
information recording medium and a magnetic disk.

Glass substrates are widely used as substrates for information recording
medium, particularly for magnetic disks, and a commercially available glass substrate
has been known, which has a composition comprising, as represented by mol%, SiO₂:
10 65.4%, Al₂O₃: 8.6%, Li₂O: 12.5%, Na₂O: 10.5% and ZrO₂: 3.0%. This commercially
available glass is subjected to chemical strengthening treatment for use.

On the other hand, Patent Document 1 proposes a substrate glass for a
magnetic disk, which is not subjected to chemical strengthening treatment.

Patent Document 1: JP-A-2002-358626 (Tables 1 to 14)

15 Since an acid having a low pH is used in a step of polishing or washing a glass
substrate for a magnetic disk, the glass substrate for a magnetic disk is required to be
free from surface roughening in the polishing step or washing step at a low pH, i.e. to
have acid resistance. Further, by using an acid having a low pH, it is possible to
improve the polishing rate or the performance to remove defects in the washing step.
20 However, in the case of glass having poor acid resistance, if an acid having a low pH is
used, the polishing rate becomes low, or defects tend to remain after washing to
deteriorate the quality.

A glass substrate for a magnetic disk is required to have a property such that a
film such as a base film, a magnetic film or a protective film, which is formed on the

substrate, is prevented from peeling due to remarkable change of a surface condition during storage, namely it is required to have weather resistance. Alkali metal components such as Li, Na and K are widely used as a glass melt accelerator. However, such components are selectively extracted from glass by moisture in air, and they are finally reacted with a component such as carbonic acid gas or sulfur dioxide gas in air and attach on a glass surface in the form of an alkali metal carbonate or an alkali metal sulfate (white stain). Therefore, it is required to prevent such a reaction.

Further, if an alkali metal component diffuses to a magnetic film, a phenomenon such that recorded information is erased tends to occur. Therefore, there is a problem that reliability of recording medium is impaired.

The present inventors conducted the after-mentioned weather resistance test on the above-mentioned commercially available chemically strengthened glass, and the result was that the total precipitation amount C_R of Li, Na and K was 3.5 nmol/cm^2 , (after-mentioned Example 123). With one not chemically strengthened, C_R was 18.3 nmol/cm^2 (after-mentioned Example 124). With one not chemically strengthened, the weather resistance was low, and it is evident that the weather resistance can be improved by the chemical strengthening treatment. That is, it is considered that this glass can be made useful as a glass substrate for a magnetic disk for the first time by the chemical strengthening treatment, and the reason is considered to be such that the amount of an alkali component having a large ion radius increases on the glass surface along with the chemical strengthening treatment, and the mobility is reduced. However, there are problems such that the chemical strengthening treatment increases the number of manufacturing steps, thus leading to an increase of cost, and the substrate surface tends to be stained by the chemical strengthening treatment.

On the other hand, most of the compositions exemplified in Patent Document 1 contain at least 1 mol% of B_2O_3 in addition to an alkali metal component. B_2O_3 is added in order to e.g. lower the brittleness of glass, lower the specific gravity or improve the melting property of glass. However, if B_2O_3 coexists with an alkali metal component, an alkali metal borate compound having an extremely low vapor pressure is formed, and the alkali metal borate component volatilizes and diffuses from the glass melt vigorously.

Fig. 1 shows a vapor pressure curve of a boron compound calculated from

thermodynamic data disclosed in Malcolm W. Chase, Jr., NIST-JANAF

Thermochemical Tables, (U.S.A.), fourth edition, the American Chemical Society and American Institute of Physics, Year 1998, p.242-274. Vapor pressure P was

calculated from the free energy difference ΔG between gas phase and condensed

5 phase at each temperature by the following formula. Results are shown on Fig. 1.

$$\Delta G = RT \ln P$$

Here, R is a gas constant.

It is evident from Fig. 1 that the vapor pressure of the alkali compound of boron is by far higher than that of B_2O_3 . Due to such a phenomenon, non-homogeneity such

10 as striation occurs, and the quality of glass deteriorates, and at the same time, there are problems such that volatilized materials are condensed on refractories used for a glass melting furnace, and the refractory strength is thereby substantially lowered, and enormous cost is required to recover the volatilized substances.

Further, in order to study the influence of the content of B_2O_3 on volatilization of
15 alkali metal components from glass, each glass of the after mentioned Examples 29, 137 and 138 was put in a platinum crucible and left for 23 hours at 1,600°C, and the amount of Li_2O and the amount of Na_2O in the glass were analyzed by ICP-MS before and after leaving it in the platinum crucible. Further, the contents of B_2O_3 in the glass of Examples 29, 137 and 138 were 0 mol%, 1 mol% and 1.5 mol%, respectively.

20 As a result, the reduced amounts of Li_2O (absolute amounts) before and after leaving the glass of Examples 29, 137 and 138 in the platinum crucible were 0.0 mass%, 0.1 mass% and 0.1 mass%, respectively. The reduced amounts of Na_2O (absolute amount) were 0.4 mass%, 0.8 mass% and 0.9 mass%, respectively. That is, between Example 29 wherein B_2O_3 was not contained and Examples 137 and 138
25 wherein at least 1 mol% of B_2O_3 was contained, the reduced amount of Na_2O was remarkably different.

Further, in Patent Document 1, five examples of containing no B_2O_3 are shown. However, in each of such examples, the content of alkali metal components in glass was large, and C_R was thereby considered to be at least 12 nmol/cm², and it is
30 considered that alkali metals tend to diffuse into a magnetic film, and reliability is low. Further, the after mentioned Example 125 corresponds to the glass of Example 63 in Patent Document 1, and the after mentioned nitric acid etching rate was 181 nm/h.

Therefore, it is likely that surface roughening results in a polishing or washing step at a low pH, and the quality deteriorates.

The present inventors have considered that such problems occur due to glass which shows a high nitric acid etching rate in the acid resistance test and a large amount of precipitation of alkalis in the weather resistance test. Thus, the present invention has been accomplished in order to solve such a problem without carrying out a chemical strengthening treatment and without incorporating a large amount of B_2O_3 .

MEANS TO ACCOMPLISH PROBLEMS

The present invention provides glass for an information recording medium substrate, which comprises, as represented by mol% based on the following oxides, from 61 to 72% of SiO_2 , from 3 to 12% of Al_2O_3 , from 0 to 14.3 of Li_2O , from 0 to 22% of Na_2O , from 0 to 22% of K_2O , from 4 to 13% of MgO , from 0 to 6% of TiO_2 and from 0 to 5% of ZrO_2 , provided that the total content of Li_2O , Na_2O and K_2O (R_2O) is from 8 to 22%, the ratio of the content of Li_2O to R_2O (Li_2O/R_2O) is at most 0.52, the ratio of the content of Na_2O to R_2O (Na_2O/R_2O) is at least 0.35, or the ratio of the content of K_2O to R_2O (K_2O/R_2O) is at least 0.45. Here, for example "comprises from 0 to 14.3 of Li_2O " means that although Li_2O is not essential, Li_2O may be contained up to 14.3 %.

Further, the present invention provides the above glass for an information recording medium substrate, wherein Al_2O_3 is from 3 to 11%, and R_2O is from 10 to 22%.

Further, the present invention provides the above glass for an information recording medium substrate, wherein SiO_2 is from 62 to 71%, Al_2O_3 is from 4 to 10%, Li_2O is from 0 to 13%, Na_2O is from 0 to 20%, K_2O is from 0 to 20%, MgO is from 5 to 12%, TiO_2 is from 0 to 5%, ZrO_2 is from 0 to 5%, and R_2O is from 11 to 20%.

Further, the present invention provides the above glass for an information recording medium substrate, wherein SiO_2 is from 63 to 70%, Al_2O_3 is from 5 to 9%, Li_2O is from 0 to 12.4%, Na_2O is from 0 to 19%, K_2O is from 0 to 19%, MgO is from 5 to 11%, TiO_2 is from 0 to 4%, ZrO_2 is from 0 to 4%, and R_2O is from 13 to 19%.

Further, the present invention provides the above glass for an information recording medium substrate, which contains neither CaO , SrO nor BaO , which contains at least one of CaO , SrO and BaO in the total content of at most 3%, or which

contains from 0 to less than 5% of Li_2O and from more than 2% to 8% of CaO .

In the above glass, the first and second embodiments of glass, namely the glass for an information recording medium substrate, wherein the total content of CaO , SrO and BaO ($\text{CaO} + \text{SrO} + \text{BaO}$) is from 0 to 3% is preferred when it is desired to increase the specific modulus and the average linear expansion coefficient (hereinafter, glass of the first and second embodiments of glass is referred to as "glass A").

The glass of the third embodiment, namely the glass for an information recording medium substrate wherein Li_2O is from 0 to less than 5%, and CaO is from more than 2% to 8% is preferred when it is desired to make the glass transition temperature to be high (hereinafter, the glass of the third embodiment is referred to as "glass B").

Further, the present invention provides glass for an information recording medium which contains no B_2O_3 , or contains less than 1% of B_2O_3 .

Further, the present invention provides a glass substrate for an information recording medium which is made of the above glass for an information recording medium substrate.

Further, the present invention provides a magnetic disk having a magnetic recording layer formed on such a glass substrate for an information recording medium.

Further, the present invention provides the followings including some of the above-mentioned features.

1. Glass for an information recording medium substrate, which comprises, as represented by mol% based on the following oxides, from 61 to 72% of SiO_2 , from 3 to 12% of Al_2O_3 , from 0 to 14.3 of Li_2O , from 0 to 22% of Na_2O , from 0 to 22% of K_2O , from 4 to 13% of MgO , from 0 to 6% of TiO_2 and from 0 to 5% of ZrO_2 , provided that the total content of Li_2O , Na_2O and K_2O (R_2O) is from 8 to 22%, the ratio of the content of Li_2O to R_2O ($\text{Li}_2\text{O}/\text{R}_2\text{O}$) is at most 0.52, the ratio of the content of Na_2O to R_2O ($\text{Na}_2\text{O}/\text{R}_2\text{O}$) is at least 0.35, or the ratio of the content of K_2O to R_2O ($\text{K}_2\text{O}/\text{R}_2\text{O}$) is at least 0.45.

2. The glass for an information recording medium substrate according to the above 1, wherein the ratio of $\text{Li}_2\text{O}/\text{R}_2\text{O}$ is at most 0.5, or the ratio of $\text{Na}_2\text{O}/\text{R}_2\text{O}$ is at least 0.4.

3. The glass for an information recording medium substrate according to the

above 1 or 2, wherein the total content of TiO_2 and ZrO_2 ($\text{TiO}_2 + \text{ZrO}_2$) is from 0 to 8%.

4. The glass for an information recording medium substrate according to any one of the above 1 to 3, which contains no B_2O_3 or contains less than 1% of B_2O_3 .

5. The glass for an information recording medium substrate according to any one of the above 1 to 4, wherein the difference obtained by deducting the content of Al_2O_3 from the content of SiO_2 exceeds 53%.

6. The glass for an information recording medium substrate according to any one of the above 1 to 5, wherein the difference obtained by deducting the content of Li_2O from the content of K_2O is at most 9%.

10 7. The glass for an information recording medium substrate according to any one of the above 1 to 6, wherein R_2O is at least 10%.

8. The glass for an information recording medium substrate according to any one of the above 1 to 6, wherein SiO_2 is from 62 to 71%, Al_2O_3 is from 4 to 12%, Li_2O is from 0 to 12.4%, Na_2O is from 0 to 20%, K_2O is from 0 to 19%, MgO is from 5 to 12%,
15 TiO_2 is from 0 to 5%, ZrO_2 is from 0 to 4%, and R_2O is from 11 to 20%.

9. The glass for an information recording medium substrate according to any one of the above 1 to 8, wherein the content of Al_2O_3 is at most 11%.

10. The glass for an information recording medium substrate according to any one of the above 1 to 6, wherein SiO_2 is from 63 to 70%, Al_2O_3 is from 5 to 9%, Li_2O is from 0 to 10.2%, Na_2O is from 0 to 19%, K_2O is from 0 to 12.8%, MgO is from 5 to
20 11%, TiO_2 is from 0 to 4%, ZrO_2 is from 0 to 4%, and R_2O is from 13 to 19%.

11. The glass for an information recording medium substrate according to any one of the above 1 to 10, which contains neither CaO , SrO nor BaO .

12. The glass for an information recording medium substrate according to any one of the above 1 to 10, which contains at least one of CaO , SrO and BaO in the total
25 content of at most 3%.

13. The glass for an information recording medium substrate according to any one of the above 1 to 6, wherein Al_2O_3 is from 3 to 11%, Li_2O is from 0 to less than 5%, Na_2O is from 0 to 13%, K_2O is from 0 to 12%, MgO is from 4 to 11%, R_2O is from 8 to
30 17%, and CaO is from more than 2% to 8%.

14. The glass for an information recording medium substrate according to any one of the above 1 to 6, wherein SiO_2 is from 61 to 71%, Al_2O_3 is from 4 to 11%, Li_2O is from 0 to 4.5%, Na_2O is from 0 to 12%, K_2O is from 0 to 10%, MgO is from 4 to 9%, and CaO is from 2.5 to 7%.

5 15. The glass for an information recording medium substrate according to the above 13 or 14, wherein ZrO_2 is from 0.5 to 3%.

16. The glass for an information recording medium substrate according to any one of the above 1 to 15, which has a Young's modulus of at least 75 GPa and a specific modulus of at least 28 MNm/kg.

10 17. The glass for an information recording medium substrate according to any one of the above 1 to 16, which has a glass transition temperature of at least 500°C.

18. The glass for an information recording medium substrate according to the above 13, 14 or 15, which has a Young's modulus of at least 76 GPa, a specific modulus of at least 30 MNm/kg and a glass transition temperature of at least 590°C.

15 19. The glass for an information recording medium substrate according to any one of the above 1 to 18, which has an average linear expansion coefficient of at least $56 \times 10^{-7}/^\circ\text{C}$ in a temperature range of from -50 to 70°C.

20 20. The glass for an information recording medium substrate according to any one of the above 1 to 19, wherein $(T_L - T_4) < 50^\circ\text{C}$, where T_L is the liquidus temperature, and T_4 is the temperature at which the viscosity becomes 10^4 dPa·s.

21. The glass for an information recording medium substrate according to any one of the above 1 to 20, which has a density of at most 2.60 g/cm^3 .

25 22. A glass substrate for an information recording medium, which is made of the glass for an information recording medium substrate as defined in any one of the above 1 to 21.

23. The glass substrate for an information recording medium according to the above 22, wherein when immersed in 0.01 N nitric acid at 25°C, the etching rate of glass is at most 0.3 nm/h.

30 24. The glass substrate for an information recording medium according to the above 22 or 23, wherein when the glass is left under a steam atmosphere at 120°C at

0.2 MPa for 20 hours, $C_R = C_{Li} + C_{Na} + C_K$ is at most 12 nmol/cm^2 , where C_{Li} , C_{Na} and C_K are the amounts of Li, Na and K which precipitate on a surface of the glass, respectively.

25. A magnetic disk having a magnetic recording layer formed on the glass
5 substrate for an information recording medium as defined in the above 22, 23 or 24.

EFFECTS OF THE INVENTION

According to the present invention, glass for an information recording medium substrate, which has a high acid resistance can be obtained, whereby surface
10 roughening can be prevented in a polishing step or a washing step under a low pH.

Further, the polishing rate of a glass substrate for an information recording medium can be improved, whereby the efficiency of the polishing step can be improved.

Further, defects formed in the washing step can be reduced, and it is possible to
15 obtain a high quality glass substrate for an information recording medium.

Further, without carrying out a chemical strengthening treatment, it is possible to obtain glass for an information recording medium substrate, wherein the total alkali precipitation amount after the weather resistance test is low. Therefore, a film formed on the substrate such as a base film, a magnetic film or a protective film is prevented
20 from peeling.

Further, it is possible to prevent alkalis from diffusing to a magnetic film, and highly reliable recoding medium can be obtained.

Further, without carrying out a chemical strengthening treatment, a glass substrate for an information recording medium can be produced, whereby the number
25 of process steps can be reduced, and the problem of stain on the substrate surface after the chemical strengthening treatment can be solved.

Further, it is possible to obtain glass for an information recording medium substrate which has a high Young's modulus and a high specific modulus. Therefore, warpage, deflection or fluttering during disk rotation can be prevented, whereby a
30 recording medium having a high recording density can be obtained.

Further, it is possible to obtain glass for an information recording medium

substrate having a low density, whereby the motor load during disk rotation can be lowered, and it is possible to accomplish reduction of the power consumption.

Further, it is possible to obtain glass for an information recording medium substrate which has a high linear expansion coefficient. Therefore, matching in thermal expansion with other drive members made of metal becomes better, the stress caused by a temperature change becomes low, and substrate fracture, etc. are prevented.

Further, it is possible to obtain glass for an information recording medium substrate which has a low liquidus temperature, as compared with the temperature at which the viscosity becomes 10^4 dPa·s. Therefore, continuous forming is possible by e.g. a float process, a fusion method or a down draw method, whereby mass production is possible.

Further, it is possible to obtain glass for an information recording medium substrate which has a high glass transition temperature. Therefore, the temperature for heat treatment which is carried out after forming a magnetic film on the substrate can be set high, whereby it is possible to obtain an information recording medium having a high recording density.

BRIEF DESCRIPTION OF DRAWINGS

Fig. 1 shows the relationship between the temperature and the vapor pressures of B_2O_3 and an alkali compound of boron.

Fig. 2 shows the relationship between the ratios of alkali oxides (Li_2O/R_2O , Na_2O/R_2O and K_2O/R_2O) and C_R . Numerical values at respective points are C_R (unit: nmol/cm²). At the top point of Li, $Li_2O/R_2O=1$. At the top point of Na, $Na_2O/R_2O=1$. At the top point of K, $K_2O/R_2O=1$.

Fig. 3 shows the relationship between Na_2O/R_2O and C_R , when $K_2O/R_2O=0$. In the figure, $y=56x^2-77x+32$ is a formula of an approximate curve (y and x are C_R and Na_2O/R_2O , respectively, when $K_2O/R_2O=0$), and R^2 is a coefficient of determination.

BEST MODES FOR CARRYING OUT THE INVENTION

The density (d) of the glass for an information recording medium substrate of the present invention (hereinafter referred to as the glass of the present invention) is

preferably at most 2.60 g/cm^3 . If the density exceeds 2.60 g/cm^3 , motor load during disk rotation becomes high, and power consumption becomes large. Further, disk rotation is likely to be unstable. The density is preferably at most 2.54 g/cm^3 .

The glass of the present invention preferably has a Young's modulus (E) of at least 75 GPa and a specific modulus (E/d) of at least 28 MNm/kg. If E is lower than 75 GPa, or the specific modulus is lower than 28 MNm/kg, the glass tends to warp or deflect during disk rotation, and it may be difficult to obtain information recording medium having high recording density. E is more preferably at least 76 GPa, and E/d is more preferably at least 30 MNm/kg. E is particularly preferably at least 77 GPa, and E/d is particularly preferably at least 30 MNm/kg.

The glass transition temperature (T_g) of the glass of the present invention is preferably at least 500°C . If T_g is lower than 500°C , the temperature for the heat treatment for forming a magnetic layer cannot be made to be sufficiently high, and it may be difficult to increase the magnetic coercive force of the magnetic layer. T_g is more preferably at least 510°C . In the case of the glass B, T_g is typically at least 590°C .

In the glass of the present invention, $(T_L - T_4)$ is preferably less than 50°C , where T_L is the liquidus temperature, and T_4 is the temperature at which the viscosity becomes $10^4 \text{ dPa}\cdot\text{s}$ (working temperature). If $(T_L - T_4)$ is 50°C or more, it may be difficult to manufacture the glass with a float process. $(T_L - T_4)$ is more preferably less than 40°C , particularly preferably less than 30°C .

The glass of the present invention preferably has a linear expansion coefficient (α) of at least $56 \times 10^{-7}/^\circ\text{C}$ in a temperature range of from -50 to 70°C . If α is lower than $56 \times 10^{-7}/^\circ\text{C}$, the difference in the thermal expansion coefficient from other members such as a drive made of metal becomes large, and the substrate tends to fracture due to a stress caused by temperature change. α is more preferably at least $58 \times 10^{-7}/^\circ\text{C}$. Typically, α is at most $100 \times 10^{-7}/^\circ\text{C}$.

When the glass substrate of the present invention for an information recording medium (hereinafter, referred to as "glass substrate of the present invention") is left under steam atmosphere at 120°C at 0.2 MPa for 20 hours, and the amount of Li, the amount of Na and the amount of K, which precipitate on a surface of the glass are represented as C_{Li} , C_{Na} and C_{K} respectively, $C_{\text{R}} = C_{\text{Li}} + C_{\text{Na}} + C_{\text{K}}$ is preferably at most 12

nmol/cm². If C_R exceeds 12 nmol/cm², a film formed on the substrate, such as a base film, a magnetic film and a protective film is likely to be peeled. C_R is more preferably at most 11 nmol/cm².

It is preferred that the glass substrate of the present invention is excellent in acid resistance such that the following nitric acid etching rate is at most 0.3 nm/h. Otherwise, in a case where a strong acid having a pH of from 1 to 2 is used in a surface polishing step or final washing step in the production process of information recording medium, particularly the production process of substrate glass for a magnetic disk, the glass surface may be roughened or peel-broken. The nitric acid etching rate is more preferably at most 0.2 nm/h.

The nitric acid etching rate: A sample to be measured is prepared by polishing a glass plate into mirror surface having a thickness of from 1 to 2 mm and a size of 4 cm × 4 cm. The sample is immersed in 0.01N nitric acid at 25°C for 3 hours, and an Si amount eluted into the nitric acid is analyzed and measured by ICP-OES.

The nitric acid etching amount is calculated from the Si amount to be obtained, the SiO₂ content in the glass and the density of the glass.

Next, the composition of the glass of the present invention is explained by employing mol% representation.

SiO₂ is a component for forming the glass structure and an essential component. If the content of SiO₂ is less than 61%, the acid resistance and weather resistance become low, d tends to be large, or T_L increases whereby the glass becomes unstable. The content of SiO₂ is preferably at least 62%, more preferably at least 63%. If the content of SiO₂ exceeds 72%, the after-mentioned T_2 and T_4 raise, and it is difficult to melt and form glass, E or E/d decreases, or α decreases. The content of SiO₂ is preferably at most 71%, more preferably at most 70%.

Al₂O₃ has an effect to improve weather resistance and is an essential component. If the content of Al₂O₃ is less than 3%, the above effect is a little, E or E/d decreases, or T_g tends to be low. The content of Al₂O₃ is preferably at least 4%, more preferably at least 5%. If the content of Al₂O₃ exceeds 12%, the acid resistance deteriorates, the after-mentioned T_2 and T_4 raise, and it is difficult to melt and form glass, α decreases, or T_L becomes too high. The content of Al₂O₃ is preferably at most 11%, more preferably at most 10%, typically at most 9%.

The difference obtained by deducting the content of Al_2O_3 from the content of SiO_2 ($\text{SiO}_2\text{-Al}_2\text{O}_3$) preferably exceeds 53%. If $\text{SiO}_2\text{-Al}_2\text{O}_3$ is at most 53%, the acid resistance may be insufficient.

Although Li_2O is not an essential component, Li_2O has an effect to increase E,
5 E/d or α , or improve the melting property of glass. Li_2O may be contained up to 14.3%. If the content of Li_2O exceeds 14.3%, the acid resistance or weather resistance deteriorates, or T_g tends to be low. The content of Li_2O is preferably at most 13%, more preferably at most 12.4%. When it is desired to increase E/d or α , for example in the glass A, the content of Li_2O is preferably at most 11%, more
10 preferably at most 10.2%, typically at most 9.5%. When it is desired to raise T_g , Li_2O is not contained, or less than 5% of Li_2O may preferably be contained. The content of Li_2O is typically from 0 to 4.5%.

Although Na_2O is not is an essential component, Na_2O has an effect to increase α or improve the melting property of glass, and Na_2O may be contained up to 22%. If
15 the content of Na_2O exceeds 22%, the acid resistance or weather resistance deteriorates, or T_g tends to be low. The content of Na_2O is preferably at most 20%, more preferably at most 19%, typically at most 18%. When it is desired to raise T_g , the content of Na_2O is preferably at most 13%, more preferably at most 12%, typically at most 11%.

20 Although K_2O is not an essential component, K_2O has an effect to increase α or improve the melting property of glass, and K_2O may be contained up to 22%. If the content of K_2O exceeds 22%, the acid resistance or weather resistance deteriorates, or E or E/d tends to be low. The content of K_2O is preferably at most 20%, more preferably at most 19%, particularly preferably at most 13%, further preferably at most
25 12.8%, typically at most 12.5%. When it is desired to raise T_g , the content of K_2O is preferably at most 12%, more preferably at most 10%, typically at most 9%.

When it is desired to increase E/d, the difference obtained by deducting the content of Li_2O from the content of K_2O ($\text{K}_2\text{O-Li}_2\text{O}$) is preferably at most 9%, typically at most 8.5%.

30 If the total content of Li_2O , Na_2O and K_2O (R_2O) is less than 8%, α decreases, or the melting property of glass deteriorates. R_2O is preferably at least 9%, more preferably at least 10%. When it is desired to increase E/d or α , for example in the

glass A, R_2O is preferably at least 11%, more preferably at least 13%. If R_2O exceeds 22%, the weather resistance deteriorates. R_2O is preferably at most 20%, more preferably at most 19%. In the glass B, R_2O is preferably at most 17%, more preferably at most 15%.

Fig. 2 shows the relationship between the weather resistance and the ratio of alkali oxide components. It is evident from Fig. 1 that C_R strongly depends on the ratio of alkali oxide components, and if Li_2O/R_2O exceeds 0.52, Na_2O/R_2O is less than 0.35, and K_2O/R_2O is less than 0.45, the weather resistance deteriorates. Li_2O/R_2O is preferably at most 0.5, or Na_2O/R_2O is preferably at least 0.4.

As mentioned above, Li_2O has an effect to increase E , E/d or α , and Na_2O and K_2O have an effect to increase α , however, the weather resistance deteriorates due to each of Li_2O , Na_2O and K_2O . On the other hand, in the case of MgO , while maintaining the weather resistance, E , E/d or α can be increased. Therefore, R_2O can be decreased, and the weather resistance of glass can be improved by adding MgO . As mentioned above, MgO has an effect to increase E , E/d or α or improve the melting property of glass, while maintaining weather resistance. MgO is thereby an essential component. If the content of MgO is less than 4%, the above effects are insufficient. The content of MgO is preferably at least 5%. If the content of MgO exceeds 13%, T_L is too high. The content of MgO is preferably at most 12%, more preferably at most 11%. When it is desired to raise T_g , the content of MgO is preferably at most 9%.

CaO , SrO and BaO are not essential components. However, when it is desired to increase α or improve the melting property of glass while maintaining the weather resistance, CaO , SrO or BaO may be contained.

When it is desired to increase E or E/d , to decrease d or to lower T_L , neither CaO , SrO nor BaO is preferably contained, or at least one of CaO , SrO and BaO may be contained in the total content of at most 3%. The total content of CaO , SrO and BaO is preferably at most 2%, typically at most 1%.

For example, when it is desired that E is at least 76 GPa, E/d is at least 30 MNm/kg, and T_g is at least 590°C, the content of Li_2O is preferably from 0 to less than 5%, and the content of CaO is preferably from more than 2% to 8%. If the content of Li_2O is at least 5%, or the content of CaO is at most 2%, T_g is difficult to be at least

590°C. If the content of CaO exceeds 8%, E/d is difficult to be at least 30 MNm/kg. The content of Li_2O is preferably from 0 to 4.5%, and the content of CaO is preferably from 2.5 to 7%, and the content of Li_2O is typically from 0 to 3%, and the content of CaO is typically from 3 to 5.5%.

5 Although TiO_2 is not essential, it has an effect to increase E, E/d or T_g or improve the weather resistance. Therefore, TiO_2 may be contained up to 6%. If the content of TiO_2 exceeds 6%, T_L tends to be too high, or a phase separation phenomenon tends to occur. The content of TiO_2 is preferably at most 5%, more preferably at most 4.5%, particularly preferably at most 4%. In a case where TiO_2 is contained, its content is
10 preferably at least 0.1%.

Although ZrO_2 is not essential, it has an effect to improve the weather resistance, increase E or E/d, raise T_g or improve the melting property of glass. Therefore, ZrO_2 may be contained up to 5%. If the content of ZrO_2 exceeds 5%, d increases, or T_L tends to be too high. The content of ZrO_2 is preferably at most 4%, typically at most
15 2.5%. When it is desired to raise T_g , the content of ZrO_2 is typically at least 0.5% and preferably at most 3%.

The total content of TiO_2 and ZrO_2 ($\text{TiO}_2 + \text{ZrO}_2$) is preferably from 0 to 8%. If the content of $\text{TiO}_2 + \text{ZrO}_2$ exceeds 8%, d increases, T_L tends to be too high, or a phase separation phenomenon tends to occur. The content of $\text{TiO}_2 + \text{ZrO}_2$ is more preferably
20 at most 7%, particularly preferably at most 6%, typically at most 5.5%. In a case where TiO_2 or ZrO_2 is contained, the content of $\text{TiO}_2 + \text{ZrO}_2$ is preferably at least 0.5%, more preferably at least 1%, particularly preferably at least 1.5%, typically at least 2%.

In the glass A, it is preferred that SiO_2 is from 62 to 71%, Al_2O_3 is from 4 to 12%, Li_2O is from 0 to 12.4%, Na_2O is from 0 to 20%, K_2O is from 0 to 19%, MgO is from 5
25 to 12%, TiO_2 is from 0 to 5%, ZrO_2 is from 0 to 4%, and R_2O is from 11 to 20%.

Further, in the glass A, it is more preferred that SiO_2 is from 63 to 70%, Al_2O_3 is from 5 to 9%, Li_2O is from 0 to 10.2%, Na_2O is from 0 to 19%, K_2O is from 0 to 12.8%, MgO is from 5 to 11%, TiO_2 is from 0 to 4%, ZrO_2 is from 0 to 4%, and R_2O is from 13
30 to 19%; or SiO_2 is from 63 to 70%, Al_2O_3 is from 5 to 9%, Li_2O is from 0 to 11%, Na_2O is from 0 to 18%, K_2O is from 0 to 12.5%, MgO is from 5 to 9%, TiO_2 is from 0 to 4%, ZrO_2 is from 0 to 2.5%, and R_2O is from 13 to 19%.

In the glass B, it is preferred that Al_2O_3 is from 3 to 11%, Li_2O is from 5 to less

than 5%, Na_2O is from 0 to 13%, K_2O is from 0 to 12%, MgO is from 4 to 11%, R_2O is from 8 to 17%, and CaO is from more than 2% to 8%.

Further, in the glass B, it is more preferred that SiO_2 is from 61 to 71%, Al_2O_3 is from 4 to 11%, Li_2O is from 0 to 4.5%, Na_2O is from 0 to 12%, K_2O is from 0 to 10%,
5 MgO is from 4 to 9%, and CaO is from 2.5 to 7%.

The glass of the present invention basically comprises the above components, however, other components may be contained so long as the object of the present invention is not impaired. In such a case, the total content of other components is preferably at most 5%, typically at most 2%.

10 Further, a refining agent such as SO_3 , Cl , As_2O_3 , Sb_2O_3 or SnO_2 may be contained up to 2% in total.

Further, a colorant such as Fe_2O_3 , Co_3O_4 or NiO may be contained up to 2% in total.

Further, if B_2O_3 coexists with an alkali metal component, it is likely to volatilize.
15 Therefore, it is preferred not to contain B_2O_3 . Even if B_2O_3 is contained, its content is less than 1%, preferably less than 0.5%.

Further, in a case where ZnO is contained, the total content represented by mass percentage of MgO and ZnO is preferably at most 7%, more preferably at most 6%, further preferably at most 5%, particularly preferably at most 4%.

20 Whether B_2O_3 or ZnO is contained or not, the ratio obtained by dividing the total content of MgO and ZnO represented by mass percentage by the ratio obtained by dividing the total content of SiO_2 , Al_2O_3 and B_2O_3 represented by mass percentage ($\text{MgO}+\text{ZnO}$)/($\text{SiO}_2+\text{Al}_2\text{O}_3+\text{B}_2\text{O}_3$) is preferably at most 0.08.

The glass substrate of the present invention is usually a circular glass plate.

25 The glass substrate of the present invention is typically used as a glass substrate for a magnetic disk.

The glass substrate for an magnetic disk is widely used for a 2.5 inch substrate (outside diameter of a glass substrate: 65 mm) used for laptop computers, etc. or a 1.8 inch substrate (outside diameter of a glass substrate: 48 mm) used for portable MP3
30 players, etc., and its market is expanding year by year, while it is demanded to supply the glass substrate at low price.

Mass production of plate glass is widely carried out by a continuous forming

method such as a float process, a fusion method or a down draw method. Since the glass of the present invention is glass which can be formed by a float process as mentioned above, the glass of the present invention is preferred for mass production.

The methods for producing the glass of the present invention and the glass substrate of the present invention are not particularly restricted, and various methods can be applied. For example, materials of respective components to be usually used are measured and mixed so as to constitute the desired composition and then heat-melted in a glass melting furnace. The glass is homogenized by bubbling, stirring, adding a refining agent or the like, then formed by a conventional method such as a float process, a press method, a fusion method or a down draw method and annealed. Then, as a case requires, processing such as grinding or polishing is carried out to form a glass substrate having a predetermined size and shape. The forming method is particularly preferably a float process, which is suitable for mass production. Further, a continuous forming method other than a float process, namely a fusion method or a down draw method is also preferred.

EXAMPLES

Materials of respective components were measured and mixed so as to constitute the compositions represented by mol% in the rows for from SiO_2 to ZrO_2 or B_2O_3 in Tables 1 to 18 and melted in a platinum crucible at a temperature of from 1,550 to 1,600°C for 3 to 5 hours. At the time of melting, a platinum stirrer was inserted in molten glass, and the molten glass was stirred for 2 hours to homogenize glass. Then, the molten glass was flown out, formed into a plate and annealed to room temperature at a cooling rate of 1°C/minute. Further, in Tables, R_2O represents the total content (unit: mol%) of Li_2O , Na_2O and K_2O .

Glasses of Examples 1 to 117, 126 to 132, 137 and 138 are working examples of the present invention, and glasses of Examples 118 to 125 and 133 to 136 are comparative examples. Further, glass of Example 126 to 136 were produced by without carrying out the above mentioned melting. Further, glass of Example 123 is the same as the above-mentioned commercially available chemical strengthened glass, and it was produced by chemical strengthening of the glass of Example 124.

With respect to the glass plates thus obtained, density d (unit: g/cm^3), the above-

mentioned average linear expansion coefficient α (unit: $\times 10^{-7}/^{\circ}\text{C}$), Young's modulus E (unit: GPa), specific modulus E/d (unit: MNm/kg), glass transition temperature T_g (unit: $^{\circ}\text{C}$), liquidus temperature T_L (unit: $^{\circ}\text{C}$), temperature at which the viscosity becomes 10^2 dPa·s T_2 (unit: $^{\circ}\text{C}$), temperature at which the viscosity becomes 10^4 dPa·s T_4 (unit: $^{\circ}\text{C}$), the above-mentioned C_R (unit: nmol/cm²), and the above-mentioned nitric acid etching rate were measured by the following methods. The results are shown in Tables 1 to 18, and "-" in Tables means "not measured", and a value with "*" are an estimated value from its composition.

Further, compositions of respective glasses represented by mass percentage are shown in Tables 19 to 36.

d : d was measured by Archimedes' method by using 20 to 50 g of glass having no bubble.

α : By using a differential thermal dilatometer and quartz glass as a reference material, the degree of elongation of glass at a time of raising the temperature from room temperature at a rate of $5^{\circ}\text{C}/\text{minute}$ was measured until the temperature at which glass softened, and elongation was no longer observed, namely the yield point, and an average linear expansion coefficient in a temperature range of from -50 to 70°C was calculated from the obtained thermal expansion curve.

E : With respect to a glass plate having a thickness of from 5 to 10 mm and a size of 3 cm $\times$ 3 cm, E was measured by an ultrasonic pulse-echo method.

T_g : By using a differential thermal dilatometer and quartz glass as a reference material, the degree of elongation of glass at a time of raising the temperature from room temperature at a rate of $5^{\circ}\text{C}/\text{minute}$ was measured until the yield point, and a temperature at a critical point on the obtained thermal expansion curve was determined as a glass transition temperature.

T_L : Glass was pulverized by a mortar to glass particles having a particle size of about 2 mm, the glass particles were lined up on a platinum board and heat-treated in a temperature gradient furnace for 24 hours. The highest temperature of the glass particles wherein crystal precipitated was determined as a liquidus temperature.

Further, for example, " $\geq 1150^{\circ}\text{C}$ " and " $\leq 1050^{\circ}\text{C}$ " mean "at least $1,150^{\circ}\text{C}$ " and "at most $1,050^{\circ}\text{C}$ " respectively.

T_2 and T_4 : T_2 and T_4 were measured by a rotation viscometer.

C_R : Both surfaces of a glass plate having a thickness of from 1 to 2 mm and a size of 4 cm × 4 cm were mirror-polished with cerium oxide and washed with calcium carbonate and a detergent, and then the glass plate was put in a highly accelerated stress test system (unsaturated type pressure cracker EHS-411M, manufactured by ESPEC Corp.) and left under a steam atmosphere at 120°C and 0.2 MPa for 20 hours. The tested sample and 20 ml of ultra pure water were put in a washed plastic bag provided with a zipper, a surface precipitate was dissolved with applying ultrasonic wave for 10 minutes, and respective alkali components of eluates were quantified by using ICP-MS. The amount of such eluates was converted to mol and normalized with the surface area of the test sample.

Nitric acid etching rate: The nitric acid etching rate was observed by the above-mentioned method (unit: nm/h). The results are shown in the row for "Acid resistance".

The acid resistance is strongly influenced by Al_2O_3 , and the lower the amount of Al_2O_3 is, the more the acid resistance improves. On the other hand, the weather resistance is also strongly influenced by Al_2O_3 , and the lower the amount of Al_2O_3 is, the more the weather resistance deteriorates. Further, the weather resistance is also strongly influenced by alkali components, and when the total amount of alkali components is reduced, or the ratio of alkali components is adjusted within a preferred range, the weather resistance improves. The total amount of alkali components in the glass of the present invention is reduced, compared to Example 122, and the ratio of alkali components is adjusted within an appropriate range, whereby the deterioration of the weather resistance due to the reduction of Al_2O_3 is suppressed, and the acid resistance of the glass of the present invention is superior to that of Example 122.

TABLE 1

Ex.	1	2	3	4	5	6	7	8
SiO_2	66.0	66.0	66.0	66.0	65.0	64.0	66.0	66.0
Al_2O_3	5.5	5.5	5.5	5.5	6.5	7.5	5.5	5.5
Li_2O	8.4	8.4	8.4	8.4	8.4	8.4	5.5	6.5
Na_2O	4.0	4.0	4.0	4.0	5.0	5.0	6.9	4.0
K_2O	4.6	4.6	4.6	4.6	4.6	4.6	4.6	6.5
MgO	8.0	8.0	8.0	8.0	8.0	8.0	8.0	8.0
TiO_2	2.0	0	3.5	1.0	0	0	1.0	1.0
ZrO_2	1.5	3.5	0	2.5	2.5	2.5	2.5	2.5
R_2O	17.0	17.0	17.0	17.0	18.0	18.0	17.0	17.0
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.49	0.49	0.49	0.49	0.47	0.47	0.32	0.38
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.24	0.24	0.24	0.24	0.28	0.28	0.41	0.24
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.27	0.27	0.27	0.27	0.26	0.26	0.27	0.38
d	2.50	2.53	2.47	2.51	2.51	2.52	2.52	2.51
α	69	69	73	69	73	72	75	73
E	83.5	85.7	83.6	84.2	83.3	83.8	81.7	82.2
T _g	534	545	523	540	532	540	543	546
T _L	1000	≥ 1150	1000	1100				≤ 1050
E / d	33.4	33.9	33.8	33.5	33.2	33.3	32.4	32.7
T ₂	1493*	1501*	1488*	1497*	1494*	1501*	1529*	1538*
T ₄	1058*	1081*	1041*	1070*	1069*	1078*	1099*	1106*
C _R	8.5	6.4	10.4	10.6	7.3	5.2	6.4	5.4
Acid resistance	0.07	0.07	0.07	0.10	0.11	0.11	0.07*	0.09

TABLE 2

Ex.	9	10	11	12	13	14	15	16
S i O ₂	66.0	68.0	66.0	66.0	66.0	66.0	66.0	66.0
A l ₂ O ₃	5.5	5.5	5.5	5.5	5.5	5.5	5.5	5.5
L i ₂ O	5.1	7.4	5.7	8.5	8.5	5.1	3.4	3.4
N a ₂ O	8.0	3.5	5.7	0	8.5	11.9	11.9	10.2
K ₂ O	3.9	4.1	5.7	8.5	0	0	1.7	3.4
M g O	8.0	8.0	8.0	8.0	8.0	8.0	8.0	8.0
T i O ₂	1.0	1.0	1.0	1.0	1.0	1.0	1.0	1.0
Z r O ₂	2.5	2.5	2.5	2.5	2.5	2.5	2.5	2.5
R ₂ O	17.0	15.0	17.0	17.0	17.0	17.0	17.0	17.0
Li ₂ O/R ₂ O	0.30	0.49	0.33	0.50	0.50	0.30	0.20	0.20
Na ₂ O/R ₂ O	0.47	0.24	0.33	0	0.50	0.70	0.70	0.60
K ₂ O/R ₂ O	0.23	0.27	0.33	0.50	0.00	0.00	0.10	0.20
d	2.52	2.50	2.52	2.50	2.53	2.53	2.53	2.53
α	74	65	75	73	68	71	77	78
E	81.9	84.3	81.2	78.9	86.7	83.2	81.4	80.4
T _g	547	562	545	561	541	554	556	554
T _L	≤ 1050	1150	≤ 1050	1050	≥ 1100	1050	1050	≤ 1050
E / d	32.4	33.7	32.2	31.6	34.3	32.9	32.1	31.8
T ₂	1526*	1559*	1538*	1537*	1448*	1485*	1521*	1539*
T ₄	1097*	1117*	1107*	1104*	1028*	1062*	1095*	1110*
C _R	5.2	6.1	5.9	6.1	5.7	5.7	5.3	4.6
Acid resistance	0.07*	0.06	0.08	0.07*	0.06	0.07*	0.07*	0.07*

TABLE 3

Ex.	17	18	19	20	21	22	23	24
SiO_2	66.0	64.0	64.0	63.0	63.0	63.0	63.0	63.0
Al_2O_3	5.5	5.5	7.5	7.5	7.5	8.5	7.5	7.5
Li_2O	1.7	9.4	8.0	6.5	5.9	8.4	7.8	5.9
Na_2O	15.3	4.5	10.9	11.3	11.3	10.0	10.0	11.3
K_2O	0	5.1	0	0	0	0.6	0.7	0
MgO	8.0	8.0	7.0	9.2	10.2	6.0	7.6	10.2
TiO_2	1.0	1.0	0	0	0	2.5	2.0	0.5
ZrO_2	2.5	2.5	2.5	2.5	2.0	1.0	1.5	1.5
R_2O	17.0	19.0	19.0	17.8	17.3	19.0	18.4	17.3
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.10	0.49	0.42	0.37	0.34	0.44	0.42	0.34
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.90	0.24	0.58	0.63	0.66	0.53	0.54	0.66
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0	0.27	0	0	0	0.03	0.04	0
d	2.53	2.53	2.52	2.54	2.53	2.51	2.52	2.52
α	78	75	72	72	72	74	72	72
E	79.0	84.2	85.8	85.8	84.7	85.1	85.6	84.5
T _g	583	520	534	553	556	531	534	554
T _L	≤ 1000	1050	1100		1100		≤ 1000	1100
E/d	31.2	33.3	34.0	33.8	33.5	33.9	33.9	33.6
T ₂	1522*	1435*	1452*	1451*	1456*	1463*	1444*	1454*
T ₄	1097*	1023*	1032*	1046*	1050*	1028*	1024*	1044*
C _R	8.5	7.9	5.7	4.5	4.4	7.0	8.1	6.2
Acid resistance	0.07	0.06	0.06	0.12	0.12	0.16	0.14	0.11

TABLE 4

Ex.	25	26	27	28	29	30	31	32
SiO_2	63.0	63.0	63.0	63.0	63.0	70.0	66.0	66.0
Al_2O_3	7.5	7.5	7.5	7.5	7.5	5.5	5.5	5.5
Li_2O	5.9	5.9	5.9	5.9	5.9	6.4	1.7	0
Na_2O	11.3	11.3	11.3	11.3	11.3	3.1	8.5	17.0
K_2O	0	0	0	0	0	3.5	6.8	0
MgO	10.2	10.2	8.7	7.7	6.7	8.0	8.0	8.0
TiO_2	1.0	1.5	2.0	3.0	4.0	1.0	1.0	1.0
ZrO_2	1.0	0.5	1.5	1.5	1.5	2.5	2.5	2.5
R_2O	17.3	17.3	17.3	17.3	17.3	13.0	17.0	17.0
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.34	0.34	0.34	0.34	0.34	0.49	0.10	0
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.66	0.66	0.66	0.66	0.66	0.24	0.50	1.00
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0	0	0	0	0	0.27	0.40	0
d	2.51	2.50	2.53	2.54	2.54	2.49	2.52	2.54*
α	73	72	72	71	71	58	82	80*
E	84.5	84.3	84.8	85.2	85.2	84.7	76.8	80.0*
T _g	549	545	556	557	559	585	574	566*
T _L	1100		1080	1040	1000	≥ 1200	≤ 1100	
E/d	33.7	33.7	33.5	33.6	33.5	34.1	30.4	31.5*
T ₂	1452*	1450*	1474	1474	1479	1620*	1593*	1540*
T ₄	1038*	1033*	1044	1047	1042	1163*	1158*	1114*
C _R	7.0	8.9	5.1	4.9	4.5	4.5	6.9	9.2
Acid resistance	0.13	0.12	0.13	0.12	0.12	0.18	0.06	0.07*

TABLE 5

Ex.	33	34	35	36	37	38	39	40
SiO_2	66.0	66.0	66.0	66.0	65.8	66.0	64.0	64.0
Al_2O_3	5.5	5.5	5.5	5.5	11.0	10.0	11.0	10.0
Li_2O	0	0	0	4.3	3.0	0	4.8	4.8
Na_2O	8.5	12.8	4.3	0	13.5	14.0	12.0	12.0
K_2O	8.5	4.3	12.8	12.8	0	0	0	0
MgO	8.0	8.0	8.0	8.0	6.7	10.0	8.2	9.2
TiO_2	1.0	1.0	1.0	1.0	0	0	0	0
ZrO_2	2.5	2.5	2.5	2.5	0	0	0	0
R_2O	17.0	17.0	17.0	17.0	16.5	14.0	16.8	16.8
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0	0	0	0.25	0.18	0.00	0.29	0.29
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.50	0.75	0.25	0	0.82	1.00	0.71	0.71
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.50	0.25	0.75	0.75	0	0	0	0
d	2.53*	2.54*	2.52*	2.51*	2.45	2.45	2.46	2.46
α	85*	83*	88*	81*	74	71	72	72
E	75.1*	77.6*	72.7*	75.9*	79.9	76.9	81.3	81.9
T _g	563*	564*	561*	551*	570*	596*	564*	557*
T _L					≤ 1150		1200	≥ 1150
E/d	29.7*	30.6*	28.8*	30.3*	32.6	31.4	33.1	33.2
T ₂	1629*	1585*	1674*	1628*	1645*	1665*	1583*	1552*
T ₄	1191*	1153*	1229*	1185*	1169*	1202*	1126*	1105*
C _R	6.7	7.7	6.4	4.4	2.0	3.9	2.5	3.1
Acid resistance	0.07*	0.07*	0.07*	0.07*	0.17	0.12	0.22	0.18

TABLE 6

Ex.	41	42	43	44	45	46	47	48
SiO_2	64.0	64.5	64.0	64.0	63.7	63.4	64.0	64.0
Al_2O_3	9.5	9.5	9.5	9.1	9.1	9.4	10.0	8.0
Li_2O	4.8	3.8	4.0	5.2	5.5	5.5	5.8	5.8
Na_2O	11.5	12.0	12.3	11.5	11.5	11.5	11.5	11.5
K_2O	0	0	0	0	0	0	0	0
MgO	10.2	10.2	10.2	10.2	10.2	10.2	7.2	9.2
TiO_2	0	0	0	0	0	0	0	0
ZrO_2	0	0	0	0	0	0	1.5	1.5
R_2O	16.3	15.8	16.3	16.7	17.0	17.0	17.3	17.3
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.29	0.24	0.25	0.31	0.32	0.32	0.34	0.34
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.71	0.76	0.75	0.69	0.68	0.68	0.66	0.66
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0	0	0	0	0	0	0	0
d	2.47	2.46	2.47	2.47	2.47	2.47	2.50	2.50
α	69	69	72	71	71	71	71	70
E	83.0	81.1	81.2	81.9	82.3	83.3	83.5	83.7
T _g	559*	566*	560*	551*	547*	549*	566*	553*
T _L						≥ 1150	≤ 1100	1050
E/d	33.6	32.9	32.9	33.2	33.4	33.8	33.4	33.4
T ₂	1539*	1564*	1547*	1520*	1508*	1511*	1553*	1491*
T ₄	1098*	1119*	1107*	1082*	1073*	1076*	1110*	1067*
C _R	5.0	7.8*	8.4*	5.7	6.6	5.3	3.9	6.0
Acid resistance	0.14	0.16*	0.17*	0.20	0.11	0.17	0.18	0.10

TABLE 7

Ex.	49	50	51	52	53	54	55	56
SiO_2	64.0	64.0	64.0	64.0	64.0	64.0	64.0	64.0
Al_2O_3	9.0	9.0	9.0	9.0	9.0	9.0	9.0	9.0
Li_2O	2.5	3.0	3.5	3.0	3.0	3.0	3.0	3.0
Na_2O	4.5	4.5	4.5	3.5	1.0	4.0	4.5	2.5
K_2O	5.0	5.5	6.0	5.0	8.0	4.0	4.5	6.0
MgO	6.5	6.5	6.5	6.5	6.5	7.0	7.0	6.8
CaO	5.5	4.5	3.5	5.5	5.0	5.5	3.0	5.3
TiO_2	1.5	1.5	1.5	2.0	2.0	2.0	3.0	2.0
ZrO_2	1.5	1.5	1.5	1.5	1.5	1.5	2.0	1.5
R_2O	12.0	13.0	14.0	11.5	12.0	11.0	12.0	11.5
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.21	0.23	0.25	0.26	0.25	0.27	0.25	0.26
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.38	0.35	0.32	0.30	0.08	0.36	0.38	0.22
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.42	0.42	0.43	0.43	0.67	0.36	0.38	0.52
d	2.54	2.53	2.52	2.54	2.53	2.54	2.55	2.54
α	68	70	71	67	70	64	67	68
E	81.8	81.8	81.1	82.6	80.4	83.9	83.0	82.0
T_g	625	603	593	631	640	632	633	636
T_L	1140							
E/d	32.2	32.3	32.1	32.5	31.8	33.0	32.6	32.3
T_2	1621*	1621*	1620*	1621*	1653*	1613*	1636*	1633*
T_4	1191*	1186*	1182*	1191*	1216*	1187*	1203*	1201*
C_R	0.9*	1.1*	1.4*	0.7*	0.7*	0.7*	0.5*	0.7*
Acid resistance	0.16*	0.16*	0.16*	0.16*	0.25	0.16*	0.17	0.12

TABLE 8

Ex.	57	58	59	60	61	62	63	64
S i O ₂	64.0	63.0	62.0	62.0	64.0	64.0	64.0	64.0
A l ₂ O ₃	9.0	9.0	9.5	9.0	7.0	9.0	9.0	9.0
L i ₂ O	3.5	4.0	4.0	3.5	3.5	3.5	3.5	1.5
N a ₂ O	2.5	2.5	2.5	2.5	2.5	2.5	2.5	2.5
K ₂ O	6.0	6.0	6.5	6.0	6.0	6.0	6.0	6.0
M g O	7.0	7.5	7.5	7.0	7.0	5.0	7.0	7.0
C a O	3.0	3.0	3.0	3.0	3.0	3.0	3.0	3.0
T i O ₂	3.0	3.0	3.0	5.0	5.0	5.0	5.0	5.0
Z r O ₂	2.0	2.0	2.0	2.0	2.0	2.0	0	2.0
R ₂ O	12.0	12.5	13.0	12.0	12.0	12.0	12.0	10.0
Li ₂ O/R ₂ O	0.29	0.32	0.31	0.29	0.29	0.29	0.29	0.15
Na ₂ O/R ₂ O	0.21	0.20	0.19	0.21	0.21	0.21	0.21	0.25
K ₂ O/R ₂ O	0.50	0.48	0.50	0.50	0.50	0.50	0.50	0.60
d	2.54	2.55	2.55	2.57	2.55	2.55	2.51	2.55
α	67	68	69	75	68	70	69	65
E	82.6	83.4	82.8	83.3	82.2	81.7	80.5	80.4
T _g	635	623	626	635	618	629	619	687
T _L	≥ 1250							1200
E / d	32.5	32.7	32.4	32.4	32.2	32.0	32.1	31.5
T ₂	1646*	1615*	1610*	1612*	1597*	1658*	1639*	1691*
T ₄	1211*	1190*	1189*	1191*	1172*	1215*	1188*	1253*
C _R	0.5*	0.5*	0.4*	0.3*	0.6*	0.3*	1.0*	0.2*
Acid resistance	0.16*	0.18*	0.22*	0.21*	0.12*	0.16*	0.16*	0.16*

TABLE 9

Ex.	65	66	67	68	69	70	71	72
SiO_2	64.0	64.0	66.0	66.0	66.0	66.0	66.0	66.0
Al_2O_3	9.0	9.0	7.0	7.0	7.9	8.0	7.6	7.5
Li_2O	3.5	3.5	3.5	3.5	3.0	3.0	3.4	3.0
Na_2O	0.5	2.5	2.5	2.5	3.5	3.5	2.4	3.5
K_2O	6.0	4.0	6.0	6.0	5.1	5.1	5.7	5.8
MgO	7.0	7.0	7.0	6.0	6.0	6.0	6.0	6.5
CaO	3.0	3.0	3.0	3.0	3.0	3.0	3.0	3.5
TiO_2	5.0	5.0	3.0	4.5	3.8	3.9	4.5	2.0
ZrO_2	2.0	2.0	2.0	1.5	1.8	1.5	1.5	2.2
R_2O	10.0	10.0	12.0	12.0	11.5	11.6	11.4	12.3
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.35	0.35	0.29	0.29	0.26	0.26	0.30	0.24
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.05	0.25	0.21	0.21	0.30	0.30	0.21	0.28
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.60	0.40	0.50	0.50	0.44	0.44	0.50	0.47
d	2.55	2.56	2.53	2.53	2.53	2.53	2.53	2.54
α	63	60	64	66	65	64	64	69
E	82.2	84.5	82.3	80.8	81.4	81.6	81.5	81.7
T _g	660	652	619	595	612	613	620	612
T _L			1190	1080	1150	1200	1100	1204
E/d	32.3	33.1	32.5	32.0	32.2	32.3	32.2	32.2
T ₂	1669*	1648*	1631*	1635*	1661*	1659*	1655*	1641*
T ₄	1233*	1215*	1192*	1188*	1211*	1208*	1205*	1202*
C _R	0.2*	0.2*	1.1*	1.1*	0.7*	0.8*	0.8*	1.1*
Acid resistance	0.16*	0.16*	0.09*	0.09*	0.10*	0.10*	0.09*	0.09*

TABLE 10

Ex.	73	74	75	76	77	78	79	80
SiO_2	66.0	67.6	67.9	67.5	68.1	66.0	66.0	66.0
Al_2O_3	7.5	7.5	7.5	7.5	7.5	7.5	7.5	7.5
Li_2O	2.5	0.3	1.8	0	0.1	0	0.2	2.0
Na_2O	4.0	7.6	3.1	10.0	9.4	10.0	10.0	7.0
K_2O	5.8	3.2	6.0	1.7	2.2	3.9	3.2	4.4
MgO	6.5	6.5	6.5	6.5	6.5	6.5	6.5	6.5
CaO	4.5	4.0	4.0	4.0	4.0	4.0	4.0	4.0
TiO_2	1.0	1.7	1.5	1.2	0.3	0.3	0.8	0.8
ZrO_2	2.2	1.7	1.8	1.7	1.8	1.8	1.8	1.8
R_2O	12.3	11.0	10.9	11.6	11.8	13.9	13.4	13.4
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.20	0.03	0.16	0	0.01	0	0.02	0.15
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.33	0.69	0.29	0.86	0.80	0.72	0.75	0.52
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.47	0.29	0.55	0.14	0.19	0.28	0.24	0.33
d	2.54	2.52	2.51	2.52	2.51	2.52	2.53	2.53
α	68	65	66	67	68	77	76	71
E	81.3	79.8	79.7	79.1	78.8	77.5	78.6	81.0
T _g	613	652	637	653	646	627	625	594
T _L	1204	1100	1169	1100	1155	1100	1100	1100
E / d	32.1	31.6	31.7	31.4	31.4	30.7	31.1	32.1
T ₂	1636*	1677*	1699*	1657*	1683	1628*	1625*	1619*
T ₄	1200*	1227*	1242*	1209*	1221	1189*	1186*	1179*
C _R	1.3*	1.6	1.3	1.8	2.6	2.9*	2.4*	2.4*
Acid resistance	0.09*	0.07*	0.07*	0.07*	0.04	0.09*	0.09*	0.09*

TABLE 11

Ex.	81	82	83	84	85	86	87	88
SiO_2	66.0	66.0	65.9	67.0	67.0	67.0	67.0	66.5
Al_2O_3	7.5	7.5	7.4	7.5	7.5	7.5	7.5	7.7
Li_2O	1.5	2.3	1.5	1.2	0.8	1.3	1.0	0.6
Na_2O	7.0	7.0	7.0	7.0	7.0	7.0	7.0	8.7
K_2O	4.1	4.6	3.8	4.3	4.1	3.6	4.0	2.2
MgO	6.5	6.5	6.4	7.0	7.0	7.0	7.0	7.5
CaO	4.0	4.0	4.0	4.0	4.5	4.5	4.5	4.0
TiO_2	1.7	0.3	2.3	0.3	0.3	0.3	0.3	1.0
ZrO_2	1.8	1.8	1.6	1.8	1.8	1.8	1.7	1.8
R_2O	12.6	13.9	12.3	12.4	11.9	11.9	12.0	11.6
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.12	0.16	0.12	0.09	0.07	0.11	0.09	0.05
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.56	0.50	0.57	0.56	0.59	0.59	0.58	0.75
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.33	0.33	0.31	0.34	0.34	0.30	0.33	0.19
d	2.53	2.52	2.53	2.52	2.52	2.52	2.52	2.53
α	70	72	68	69	69	68	69	67
E	80.8	80.5	80.9	79.8	79.8	80.6	79.9	81.0
T _g	611	583	610	613	626	616	623	637
T _L	1100	1100	1122	1153	1144	1152	1163	≤ 1160
E/d	31.9	31.9	31.9	31.7	31.7	32.0	31.8	32.0
T ₂	1631*	1612*	1628*	1651*	1653*	1643*	1649*	1627
T ₄	1191*	1173*	1188*	1206*	1210*	1200*	1205*	1203
C _R	1.6*	3.0*	1.5*	2.3*	2.4	2.1*	2.1*	1.8
Acid resistance	0.09*	0.09*	0.09*	0.08*	0.05	0.08*	0.08*	0.06

TABLE 12

Ex.	89	90	91	92	93	94	95	96
SiO_2	66.7	66.8	67.0	66.2	66.5	66.4	66.8	66.8
Al_2O_3	7.7	7.7	7.6	7.7	7.7	7.7	7.7	7.7
Li_2O	0.6	0.6	1.3	0.2	1.1	0.4	0.5	0.5
Na_2O	8.7	8.7	9.0	10.0	8.7	10.0	10.0	10.0
K_2O	2.2	2.2	2.0	0.7	2.2	0.8	0.8	0.8
MgO	7.0	7.0	6.6	7.5	7.5	7.5	7.5	7.5
CaO	4.5	4.5	4.0	4.5	4.0	4.5	4.5	4.0
TiO_2	1.0	1.0	1.0	1.6	0.5	1.1	0.5	1.0
ZrO_2	1.6	1.5	1.6	1.7	1.8	1.7	1.7	1.7
R_2O	11.6	11.6	12.3	11.0	12.1	11.1	11.4	11.4
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.05	0.05	0.10	0.02	0.09	0.03	0.05	0.05
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.75	0.75	0.73	0.91	0.72	0.90	0.88	0.88
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.19	0.19	0.16	0.07	0.18	0.07	0.07	0.07
d	2.53	2.52	2.52	2.54	2.53	2.53	2.53	2.53
α	68	67	67	63	68	65	65	65
E	80.6	79.8	80.1	81.2	81.5	81.3	81.3	80.9
T _g	635	635	617	653	618	645	638	639
T _L	1160	1164	≤ 1160	1162	≤ 1154			1154
E/d	31.9	31.6	31.8	32.0	32.3	32.1	32.2	32.0
T ₂	1637*	1638*	1632*	1621*	1626*	1623*	1625*	1630*
T ₄	1197*	1197*	1187*	1189*	1189*	1189*	1189*	1192*
C _R	1.7*	1.7	2.2*	1.3*	2.0*	1.5*	1.9*	1.7*
Acid resistance	0.09*	0.07	0.08*	0.09*	0.09*	0.09*	0.08*	0.08*

TABLE 13

Ex.	97	98	99	100	101	102	103	104
SiO_2	66.4	66.0	65.4	65.0	64.6	66.1	65.7	66.2
Al_2O_3	7.7	7.7	7.7	7.7	7.7	7.7	8.0	8.0
Li_2O	0.4	0.2	0	0	0	0.9	1.1	0.9
Na_2O	10.0	10.0	9.8	9.3	8.8	10.0	10.0	10.0
K_2O	0.8	0.7	0.7	1.0	1.3	0.5	0.4	0.5
MgO	7.5	7.5	7.5	7.5	7.5	7.5	7.5	7.5
CaO	4.0	4.0	4.0	4.0	4.0	4.0	4.0	4.0
TiO_2	1.6	2.2	3.2	3.9	4.5	1.6	1.6	1.1
ZrO_2	1.7	1.7	1.7	1.7	1.7	1.7	1.7	1.7
R_2O	11.2	10.9	10.6	10.3	10.1	11.4	11.5	11.5
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.04	0.02	0	0	0	0.08	0.09	0.08
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.89	0.91	0.93	0.90	0.88	0.88	0.87	0.87
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.07	0.07	0.07	0.10	0.12	0.04	0.04	0.05
d	2.53	2.55	2.54	2.56	2.56	2.54	2.54	2.53
α	65	64	65	65	65	65	64	64
E	81.2	81.0	81.2	81.3	81.3	81.9	82.4	81.9
T _g	643	661	653	668	671	635	631	637
T _L	≤ 1151	1153	1170	1191	1220	1148	1162	1169
E/d	32.0	31.8	32.0	31.8	31.8	32.3	32.5	32.4
T ₂	1626*	1624*	1621*	1619*	1618*	1614*	1609*	1622*
T ₄	1191*	1191*	1192*	1193*	1193*	1181*	1178*	1187*
C _R	1.4*	1.1*	0.8*	0.6*	0.5*	1.4*	1.3*	1.4*
Acid resistance	0.09*	0.10*	0.10*	0.11*	0.12*	0.09*	0.10*	0.10*

TABLE 14

Ex.	105	106	107	108	109	110	111	112
SiO_2	66.7	66.5	66.5	66.5	66.0	64.0	66.5	66.2
Al_2O_3	8.0	7.5	7.5	7.5	7.5	7.5	7.5	8.5
Li_2O	0.8	0.5	1.0	3.0	1.0	3.0	3.0	0.8
Na_2O	10.0	7.0	6.5	4.5	7.0	7.0	2.5	10.0
K_2O	0.9	2.5	2.5	2.5	2.5	2.5	4.5	0.9
MgO	7.5	7.5	7.5	7.5	7.5	7.5	7.5	7.5
CaO	4.0	4.0	4.0	4.0	4.0	4.0	4.0	4.0
TiO_2	0.5	3.0	3.0	3.0	3.0	3.0	3.0	0.5
ZrO_2	1.7	1.5	1.5	1.5	1.5	1.5	1.5	1.7
R_2O	11.6	10.0	10.0	10.0	10.5	12.5	10.0	11.6
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.07	0.05	0.10	0.30	0.10	0.24	0.30	0.07
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.86	0.70	0.65	0.45	0.67	0.56	0.25	0.86
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.07	0.25	0.25	0.25	0.24	0.20	0.45	0.07
d	2.52	2.53	2.53	2.53	2.54	2.55	2.53	2.53
α	64	63	64	59	65	66	63	63
E	81.5	81.3	82.2	84.7	82.3	84.9	83.0	81.4
T _g	643	659	648	626	642	598	634	656
T _L	1150	≤ 1190	≤ 1191	1200	1151	≤ 1145	≥ 1222	
E/d	32.3	32.1	32.5	33.5	32.4	33.2	32.9	32.1
T ₂	1632*	1654*	1649*	1627*	1635*	1557*	1648*	1636*
T ₄	1193*	1214*	1209*	1189*	1199*	1137*	1207*	1198*
C _R	1.7*	0.9*	0.9*	0.9*	0.9*	1.4*	0.9*	1.4*
Acid resistance	0.09*	0.09*	0.09*	0.09*	0.09*	0.12*	0.09*	0.11*

TABLE 15

Ex.	113	114	115	116	117	118	119	120
SiO_2	65.7	65.2	64.7	66.3	64.7	66.0	66.0	66.0
Al_2O_3	9.0	9.5	10.0	5.5	5.5	5.5	5.5	5.5
Li_2O	0.7	0.7	0.7	0.1	2.7	9.9	9.5	11.0
Na_2O	10.0	10.0	10.0	10.0	10.0	4.0	2.5	0
K_2O	0.9	0.9	0.9	1.2	0.2	3.1	5.0	6.0
MgO	7.5	7.5	7.5	7.5	7.5	8.0	8.0	8.0
CaO	4.0	4.0	4.0	6.0	6.0	0	0	0
TiO_2	0.5	0.5	0.5	1.4	1.4	1.0	1.0	1.0
ZrO_2	1.7	1.7	1.7	2.0	2.0	2.5	2.5	2.5
R_2O	11.6	11.6	11.6	11.3	12.9	17.0	17.0	17.0
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.06	0.06	0.06	0.01	0.21	0.58	0.56	0.65
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.86	0.86	0.86	0.88	0.78	0.24	0.15	0
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0.07	0.07	0.07	0.10	0.01	0.18	0.29	0.35
d	2.53	2.53	2.53	2.56	2.57	2.51	2.51	2.50
α	64	64	63	67	67	67	68	65
E	81.8	82.2	82.3	78.8	85.4	86.3	84.3	83.7
T _g	643	651	654	625	592	541	544	552
T _L	≥ 1195	≥ 1191	≥ 1193				≥ 1150	≥ 1150
E/d	32.4	32.5	32.5	30.8	33.2	34.3	33.6	33.5
T ₂	1641*	1645*	1649*	1557*	1473*	1465*	1489*	1483*
T ₄	1204*	1208*	1213*	1143*	1075*	1041*	1062*	1056*
C _R	1.1*	0.9*	0.7*	2.5*	3.6*	19.5	15.1	21.5
Acid resistance	0.12*	0.14*	0.16*	0.07*	0.08*	0.09	0.07*	0.08

TABLE 16

Ex.	121	122	123	124	125	126	127	128
S i O ₂	66.0	64.5	65.4	65.4	60.0	66.0	70.0	62.0
A l ₂ O ₃	5.5	12.0	8.6	8.6	15.0	5.5	3.5	8.5
L i ₂ O	15.3	12.8	12.5	12.5	9.0	10.2	4.0	5.5
N a ₂ O	1.7	5.5	10.5	10.5	9.0	6.8	5.0	7.0
K ₂ O	0	3.4	0	0	2.0	0	5.0	8.0
M g O	8.0	0	0	0	5.0	8.0	8.0	6.5
C a O	0	0	0	0	0	0	0	0
S r O	0	0	0	0	0	0	0	0
B a O	0	0	0	0	0	0	0	0
T i O ₂	1.0	0	0	0	0	1.0	3.0	1.0
Z r O ₂	2.5	1.8	3.0	3.0	0	2.5	1.5	1.5
R ₂ O	17.0	21.7	23.0	23.0	20.0	17.0	14.0	20.5
Li ₂ O/R ₂ O	0.90	0.59	0.54	0.54	0.45	0.60	0.29	0.27
Na ₂ O/R ₂ O	0.10	0.25	0.46	0.46	0.45	0.40	0.36	0.34
K ₂ O/R ₂ O	0	0.16	0	0	0.10	0	0.36	0.39
d	2.51	2.47		2.50	2.46*	2.52*	2.49*	2.51*
α	57	74		75	74*	64*	68*	87*
E	91.5	82.7		85.6	83.2*	87.8*	80.1*	77.8*
T _g	543	523		504	550*	543*	564*	525*
T _L	≥ 1050	1050						
E / d	36.5	33.5		34.2	33.8*	34.8*	32.1*	31.0*
T ₂	1374*	1594		1454*	1573*	1430*	1598*	1537*
T ₄	958*	1093		998*	1111*	1011*	1140*	1102*
C _R	24.6	3.2	3.5	18.3	3.6	10.0*	11.7*	6.6*
Acid resistance	0.07*	0.25		0.05	181	0.07*	0.03*	0.19*

TABLE 17

Ex.	129	130	131	132	133	134	135	136
S i O ₂	63.0	63.0	63.0	63.2	60.0	70.0	68.0	66.0
A l ₂ O ₃	9.5	9.5	9.5	7.0	10.0	2.5	7.8	10.0
L i ₂ O	0.5	6.0	6.0	3.0	7.0	5.0	1.0	5.0
N a ₂ O	18.0	0	6.5	9.0	8.5	5.0	7.0	5.5
K ₂ O	0	12.5	6.5	6.0	6.0	5.0	11.0	0
M g O	6.5	6.5	8.5	5.0	8.0	8.0	3.0	5.0
C a O	0	0	0	1.8	0	0	0	4.0
S r O	0	0	0	0.1	0	0	0	0
B a O	0	0	0	0.1	0	0	0	0
T i O ₂	1.0	1.0	0	3.0	0	3.0	1.0	3.0
Z r O ₂	1.5	1.5	0	1.8	0.5	1.5	1.2	1.5
R ₂ O	18.5	18.5	19.0	18.0	21.5	15.0	19.0	10.5
Li ₂ O/R ₂ O	0.03	0.32	0.32	0.17	0.33	0.33	0.05	0.48
Na ₂ O/R ₂ O	0.97	0	0.34	0.50	0.40	0.33	0.37	0.52
K ₂ O/R ₂ O	0	0.68	0.34	0.33	0.28	0.33	0.58	0
d	2.53*	2.49*	2.46*	2.55*	2.49*	2.49*	2.47*	2.53*
α	83*	82*	81*	78*	87*	70*	90*	53*
E	79.5*	76.4*	78.5*	78.6*	79.5*	80.3*	70.5*	86.5*
T _g	567*	549*	526*	526*	509*	544*	538*	635*
T _L								
E/d	31.4*	30.7*	32.0*	30.8*	32.0*	32.2*	28.6*	34.2*
T ₂	1572*	1643*	1557*	1544*	1479*	1551*	1739*	1643*
T ₄	1133*	1189*	1109*	1114*	1053*	1099*	1241*	1189*
C _R	3.9*	2.7*	11.6*	3.9*	10.6*	21.5*	8.9*	0.5*
Acid resistance	0.19*	0.19*	0.19*	0.13*	0.32*	0.02*	0.07*	0.13*

TABLE 18

Ex.	137	138
SiO_2	63.0	63.0
Al_2O_3	7.5	7.5
Li_2O	5.9	5.9
Na_2O	11.3	11.3
K_2O	0	0
MgO	6.7	6.7
TiO_2	3.0	2.5
ZrO_2	1.5	1.5
B_2O_3	1.0	1.5
R_2O	17.3	17.3
$\text{Li}_2\text{O}/\text{R}_2\text{O}$	0.34	0.34
$\text{Na}_2\text{O}/\text{R}_2\text{O}$	0.66	0.66
$\text{K}_2\text{O}/\text{R}_2\text{O}$	0	0
d	2.53	2.52
α	71	70
E	84.2	83.8
T _g	543	541
T _L		
E / d	33.3	33.2
T ₂	1473*	1472*
T ₄	1044*	1040*
C _R	5*	5*
Acid resistance	0.14*	0.14*

TABLE 19

Ex.	1	2	3	4	5	6	7	8
SiO_2	64.7	63.8	65.4	64.3	63.1	61.7	63.3	63.0
Al_2O_3	9.2	9.0	9.3	9.1	10.7	12.3	9.0	8.9
Li_2O	4.1	4.0	4.1	4.1	4.1	4.0	2.6	3.1
Na_2O	4.0	4.0	4.1	4.0	5.0	5.0	6.8	3.9
K_2O	7.1	7.0	7.1	7.0	7.0	6.9	6.9	9.7
MgO	5.3	5.2	5.3	5.2	5.2	5.2	5.1	5.1
TiO_2	2.6	0.0	4.6	1.3	0.0	0.0	1.3	1.3
ZrO_2	3.0	6.9	0.0	5.0	5.0	4.9	4.9	4.9

TABLE 20

Ex.	9	10	11	12	13	14	15	16
SiO_2	63.4	66.1	63.0	63.0	65.9	64.7	63.6	63.0
Al_2O_3	9.0	9.1	8.9	8.9	9.3	9.2	9.0	8.9
Li_2O	2.4	3.6	2.7	4.0	4.2	2.5	1.6	1.6
Na_2O	7.9	3.5	5.6	0.0	8.8	12.0	11.8	10.0
K_2O	5.9	6.2	8.5	12.7	0.0	0.0	2.6	5.1
MgO	5.2	5.2	5.1	5.1	5.4	5.3	5.2	5.1
TiO_2	1.3	1.3	1.3	1.3	1.3	1.3	1.3	1.3
ZrO_2	4.9	5.0	4.9	4.9	5.1	5.0	4.9	4.9

TABLE 21

Ex.	17	18	19	20	21	22	23	24
SiO_2	63.6	62.4	62.8	61.8	62.2	61.6	61.9	62.4
Al_2O_3	9.0	9.1	12.5	12.5	12.6	14.1	12.5	12.6
Li_2O	0.8	4.6	3.9	3.2	2.9	4.1	3.8	2.9
Na_2O	15.2	4.5	11.1	11.4	11.6	10.1	10.1	11.6
K_2O	0.0	7.9	0.0	0.0	0.0	0.9	1.0	0.0
MgO	5.2	5.2	4.6	6.0	6.8	3.9	5.0	6.8
TiO_2	1.3	1.3	0.0	0.0	0.0	3.2	2.6	0.7
ZrO_2	4.9	5.0	5.0	5.0	4.0	2.0	3.0	3.0

5

TABLE 22

Ex.	25	26	27	28	29	30	31	32
SiO_2	62.6	62.8	61.8	61.4	61.0	67.9	61.4	63.0
Al_2O_3	12.6	12.7	12.5	12.4	12.3	9.1	8.7	8.9
Li_2O	2.9	2.9	2.9	2.9	2.9	3.1	0.8	0.0
Na_2O	11.6	11.7	11.5	11.4	11.3	3.1	8.2	16.8
K_2O	0.0	0.0	0.0	0.0	0.0	5.4	9.9	0.0
MgO	6.8	6.8	5.7	5.0	4.4	5.2	5.0	5.1
TiO_2	1.3	2.0	2.6	3.9	5.1	1.3	1.2	1.3
ZrO_2	2.0	1.0	3.0	3.0	3.0	5.0	4.8	4.9

TABLE 23

Ex.	33	34	35	36	37	38	39	40
SiO_2	60.4	61.7	59.2	60.4	63.0	63.4	62.2	62.8
Al_2O_3	8.5	8.7	8.4	8.5	17.9	16.3	18.1	16.7
Li_2O	0.0	0.0	0.0	1.9	1.4	0.0	2.3	2.3
Na_2O	8.0	12.3	3.9	0.0	13.3	13.9	12.0	12.1
K_2O	12.2	6.2	17.9	18.3	0.0	0.0	0.0	0.0
MgO	4.9	5.0	4.8	4.9	4.3	6.4	5.3	6.1
TiO_2	1.2	1.2	1.2	1.2	0.0	0.0	0.0	0.0
ZrO_2	4.7	4.8	4.6	4.7	0.0	0.0	0.0	0.0

TABLE 24

Ex.	41	42	43	44	45	46	47	48
SiO_2	63.2	63.4	63.0	63.5	63.3	62.9	61.8	63.0
Al_2O_3	15.9	15.8	15.9	15.3	15.4	15.8	16.4	13.4
Li_2O	2.4	1.9	2.0	2.6	2.7	2.7	2.8	2.8
Na_2O	11.7	12.2	12.5	11.8	11.8	11.8	11.4	11.7
K_2O	0.0	0.0	0.0	0.0	0.0	0.0	0.0	0.0
MgO	6.8	6.7	6.7	6.8	6.8	6.8	4.7	6.1
TiO_2	0.0	0.0	0.0	0.0	0.0	0.0	0.0	0.0
ZrO_2	0.0	0.0	0.0	0.0	0.0	0.0	3.0	3.0

5

TABLE 25

Ex.	49	50	51	52	53	54	55	56
SiO_2	59.5	59.4	59.4	59.6	58.7	60.0	59.2	59.3
Al_2O_3	14.2	14.2	14.2	14.2	14.0	14.3	14.1	14.2
Li_2O	1.2	1.4	1.6	1.4	1.4	1.4	1.4	1.4
Na_2O	4.3	4.3	4.3	3.4	0.9	3.9	4.3	2.4
K_2O	7.3	8.0	8.7	7.3	11.5	5.9	6.5	8.7
MgO	4.1	4.0	4.0	4.1	4.0	4.4	4.3	4.2
CaO	4.8	3.9	3.0	4.8	4.3	4.8	2.6	4.5
TiO_2	1.9	1.9	1.9	2.5	2.4	2.5	3.7	2.5
ZrO_2	2.9	2.9	2.9	2.9	2.8	2.9	3.8	2.9

TABLE 26

Ex.	57	58	59	60	61	62	63	64
SiO_2	58.9	58.2	57.0	56.8	59.3	58.2	59.7	58.1
Al_2O_3	14.1	14.1	14.8	14.0	11.0	13.9	14.3	13.9
Li_2O	1.6	1.8	1.8	1.6	1.6	1.6	1.6	0.7
Na_2O	2.4	2.4	2.4	2.4	2.4	2.3	2.4	2.3
K_2O	8.7	8.7	9.4	8.6	8.7	8.6	8.8	8.5
MgO	4.3	4.7	4.6	4.3	4.4	3.1	4.4	4.3
CaO	2.6	2.6	2.6	2.6	2.6	2.5	2.6	2.5
TiO_2	3.7	3.7	3.7	6.1	6.2	6.0	6.2	6.0
ZrO_2	3.8	3.8	3.8	3.8	3.8	3.7	0.0	3.7

TABLE 27

Ex.	65	66	67	68	69	70	71	72
SiO_2	58.6	59.2	61.6	61.4	61.1	61.3	61.3	61.3
Al_2O_3	14.0	14.1	11.1	11.1	12.5	12.5	11.9	11.8
Li_2O	1.6	1.6	1.6	1.6	1.4	1.4	1.6	1.4
Na_2O	0.5	2.4	2.4	2.4	3.4	3.4	2.3	3.4
K_2O	8.6	5.8	8.8	8.8	7.3	7.4	8.2	8.4
MgO	4.3	4.3	4.4	3.7	3.7	3.7	3.7	4.0
CaO	2.6	2.6	2.6	2.6	2.6	2.6	2.6	3.0
TiO_2	6.1	6.1	3.7	5.6	4.7	4.8	5.6	2.5
ZrO_2	3.8	3.8	3.8	2.9	3.3	2.9	2.9	4.2

5

TABLE 28

Ex.	73	74	75	76	77	78	79	80
SiO_2	61.3	63.1	63.0	63.5	64.1	61.5	61.7	61.9
Al_2O_3	11.8	11.9	11.8	12.0	12.0	11.9	11.9	11.9
Li_2O	1.2	0.1	0.8	0.0	0.1	0.0	0.1	0.9
Na_2O	3.8	7.3	3.0	9.7	9.1	9.6	9.6	6.8
K_2O	8.5	4.6	8.7	2.5	3.3	5.7	4.7	6.5
MgO	4.1	4.1	4.0	4.1	4.1	4.1	4.1	4.1
CaO	3.9	3.5	3.5	3.5	3.5	3.5	3.5	3.5
TiO_2	1.2	2.1	1.9	1.5	0.4	0.4	1.0	1.0
ZrO_2	4.2	3.4	3.3	3.4	3.4	3.3	3.4	3.4

TABLE 32

Ex.	105	106	107	108	109	110	111	112
SiO_2	63.4	62.5	62.6	63.3	62.2	60.8	62.6	62.7
Al_2O_3	12.9	12.0	12.0	12.1	12.0	12.1	12.0	13.7
Li_2O	0.4	0.2	0.5	1.4	0.5	1.4	1.4	0.4
Na_2O	9.8	6.8	6.3	4.4	6.8	6.9	2.4	9.8
K_2O	1.3	3.7	3.7	3.7	3.7	3.7	6.6	1.3
MgO	4.8	4.7	4.7	4.8	4.7	4.8	4.7	4.8
CaO	3.5	3.5	3.5	3.6	3.5	3.5	3.5	3.5
TiO_2	0.6	3.7	3.8	3.8	3.8	3.8	3.8	0.6
ZrO_2	3.3	2.9	2.9	2.9	2.9	2.9	2.9	3.3

TABLE 33

Ex.	113	114	115	116	117	118	119	120
SiO_2	62.0	61.4	60.7	63.5	63.1	65.3	64.5	64.7
Al_2O_3	14.4	15.2	15.9	8.9	9.1	9.2	9.1	9.1
Li_2O	0.3	0.3	0.3	0.1	1.3	4.9	4.6	5.4
Na_2O	9.7	9.7	9.7	9.9	10.1	4.1	2.5	0.0
K_2O	1.3	1.3	1.3	1.7	0.3	4.8	7.7	9.2
MgO	4.7	4.7	4.7	4.8	4.9	5.3	5.2	5.3
CaO	3.5	3.5	3.5	5.4	5.5	0.0	0.0	0.0
TiO_2	0.6	0.6	0.6	1.8	1.8	1.3	1.3	1.3
ZrO_2	3.3	3.3	3.3	3.9	4.0	5.1	5.0	5.0

5

TABLE 34

Ex.	121	122	123	124	125	126	127	128
SiO_2	68.4	60.9	63.4	63.4	56.8	66.4	67.7	57.6
Al_2O_3	9.7	19.2	14.1	14.1	24.1	9.4	5.7	13.4
Li_2O	7.9	6.0	6.0	6.0	4.2	5.1	1.9	2.5
Na_2O	1.8	5.4	10.5	10.5	8.8	7.1	5.0	6.7
K_2O	0.0	5.0	0.0	0.0	3.0	0.0	7.6	11.6
MgO	5.6	0.0	0.0	0.0	3.2	5.4	5.2	4.0
CaO	0.0	0.0	0.0	0.0	0.0	0.0	0.0	0.0
SrO	0.0	0.0	0.0	0.0	0.0	0.0	0.0	0.0
BaO	0.0	0.0	0.0	0.0	0.0	0.0	0.0	0.0
TiO_2	1.4	0.0	0.0	0.0	0.0	1.3	3.9	1.2
ZrO_2	5.3	3.5	6.0	6.0	0.0	5.2	3.0	2.9

TABLE 35

Ex.	129	130	131	132	133	134	135	136
S i O ₂	59.0	57.0	60.2	58.3	57.1	68.5	60.7	62.7
A l ₂ O ₃	15.1	14.6	15.4	11.0	16.2	4.2	11.8	16.1
L i ₂ O	0.2	2.7	2.8	1.4	3.3	2.4	0.4	2.4
N a ₂ O	17.4	0.0	6.4	8.6	8.3	5.0	6.4	5.4
K ₂ O	0.0	17.7	9.7	8.7	9.0	7.7	15.4	0.0
M g O	4.1	3.9	5.4	3.1	5.1	5.3	1.8	3.2
C a O	0.0	0.0	0.0	1.5	0.0	0.0	0.0	3.5
S r O	0.0	0.0	0.0	0.2	0.0	0.0	0.0	0.0
B a O	0.0	0.0	0.0	0.2	0.0	0.0	0.0	0.0
T i O ₂	1.2	1.2	0.0	3.7	0.0	3.9	1.2	3.8
Z r O ₂	2.9	2.8	0.0	3.4	1.0	3.0	2.2	2.9

TABLE 36

Ex.	137	138
S i O ₂	61.1	61.1
A l ₂ O ₃	12.3	12.4
L i ₂ O	2.9	2.9
N a ₂ O	11.4	11.4
K ₂ O	0.0	0.0
M g O	4.4	4.4
T i O ₂	3.9	3.2
Z r O ₂	3.0	3.0
B ₂ O ₃	1.1	1.7

5

INDUSTRIAL APPLICABILITY

The glass of the present invention can be used for a glass substrate for a magnetic disk.

10

The entire disclosures of Japanese Patent Application No. 2009-090104 filed on April 2, 2009 and Japanese Patent Application No. 2010-030190 filed on February 15, 2010 including specifications, claims, drawings and summaries are incorporated herein by reference in their entireties.

CLAIMS:

1. Glass for an information recording medium substrate, which comprises, as represented by mol% based on the following oxides, from 61 to 72% of SiO_2 , from 3 to 12% of Al_2O_3 , from 0 to 14.3 of Li_2O , from 0 to 22% of Na_2O , from 0 to 22% of K_2O ,
5 from 4 to 13% of MgO , from 0 to 6% of TiO_2 and from 0 to 5% of ZrO_2 , provided that the total content of Li_2O , Na_2O and K_2O (R_2O) is from 8 to 22%, the ratio of the content of Li_2O to R_2O ($\text{Li}_2\text{O}/\text{R}_2\text{O}$) is at most 0.52, the ratio of the content of Na_2O to R_2O ($\text{Na}_2\text{O}/\text{R}_2\text{O}$) is at least 0.35, or the ratio of the content of K_2O to R_2O ($\text{K}_2\text{O}/\text{R}_2\text{O}$) is at least 0.45.
- 10 2. The glass for an information recording medium substrate according to Claim 1, wherein the ratio of $\text{Li}_2\text{O}/\text{R}_2\text{O}$ is at most 0.5, or the ratio of $\text{Na}_2\text{O}/\text{R}_2\text{O}$ is at least 0.4.
3. The glass for an information recording medium substrate according to Claim 1 or 2, wherein the total content of TiO_2 and ZrO_2 ($\text{TiO}_2+\text{ZrO}_2$) is from 0 to 8%.
4. The glass for an information recording medium substrate according to any one of
15 Claims 1 to 3, which contains no B_2O_3 or contains less than 1% of B_2O_3 .
5. The glass for an information recording medium substrate according to any one of Claims 1 to 4, wherein the difference obtained by deducting the content of Al_2O_3 from the content of SiO_2 exceeds 53%.
6. The glass for an information recording medium substrate according to any one of
20 Claims 1 to 5, wherein the difference obtained by deducting the content of Li_2O from the content of K_2O is at most 9%.
7. The glass for an information recording medium substrate according to any one of Claims 1 to 6, wherein R_2O is at least 10%.
8. The glass for an information recording medium substrate according to any one of
25 Claims 1 to 6, wherein SiO_2 is from 62 to 71%, Al_2O_3 is from 4 to 12%, Li_2O is from 0 to 12.4%, Na_2O is from 0 to 20%, K_2O is from 0 to 19%, MgO is from 5 to 12%, TiO_2 is from 0 to 5%, ZrO_2 is from 0 to 4%, and R_2O is from 11 to 20%.
9. The glass for an information recording medium substrate according to any one of Claims 1 to 8, wherein the content of Al_2O_3 is at most 11%.
- 30 10. The glass for an information recording medium substrate according to any one of Claims 1 to 6, wherein SiO_2 is from 63 to 70%, Al_2O_3 is from 5 to 9%, Li_2O is from 0 to 10.2%, Na_2O is from 0 to 19%, K_2O is from 0 to 12.8%, MgO is from 5 to 11%, TiO_2 is

from 0 to 4%, ZrO_2 is from 0 to 4%, and R_2O is from 13 to 19%.

11. The glass for an information recording medium substrate according to any one of Claims 1 to 10, which contains neither CaO , SrO nor BaO .

12. The glass for an information recording medium substrate according to any one of
5 Claims 1 to 10, which contains at least one of CaO , SrO and BaO in the total content of at most 3%.

13. The glass for an information recording medium substrate according to any one of Claims 1 to 6, wherein Al_2O_3 is from 3 to 11%, Li_2O is from 0 to less than 5%, Na_2O is from 0 to 13%, K_2O is from 0 to 12%, MgO is from 4 to 11%, R_2O is from 8 to 17%, and
10 CaO is from more than 2% to 8%.

14. The glass for an information recording medium substrate according to any one of Claims 1 to 6, wherein SiO_2 is from 61 to 71%, Al_2O_3 is from 4 to 11%, Li_2O is from 0 to 4.5%, Na_2O is from 0 to 12%, K_2O is from 0 to 10%, MgO is from 4 to 9%, and CaO is from 2.5 to 7%.

15. The glass for an information recording medium substrate according to Claim 13 or 14, wherein ZrO_2 is from 0.5 to 3%.

16. The glass for an information recording medium substrate according to any one of Claims 1 to 15, which has a Young's modulus of at least 75 GPa and a specific modulus of at least 28 MNm/kg.

20 17. The glass for an information recording medium substrate according to any one of Claims 1 to 16, which has a glass transition temperature of at least 500°C.

18. The glass for an information recording medium substrate according to Claim 13, 14 or 15, which has a Young's modulus of at least 76 GPa, a specific modulus of at least 30 MNm/kg and a glass transition temperature of at least 590°C.

25 19. The glass for an information recording medium substrate according to any one of Claims 1 to 18, which has an average linear expansion coefficient of at least $56 \times 10^{-7}/^\circ\text{C}$ in a temperature range of from -50 to 70°C.

20. The glass for an information recording medium substrate according to any one of Claims 1 to 19, wherein $(T_L - T_4) < 50^\circ\text{C}$, where T_L is the liquidus temperature, and T_4 is
30 the temperature at which the viscosity becomes 10^4 dPa·s.

21. The glass for an information recording medium substrate according to any one of Claims 1 to 20, which has a density of at most 2.60 g/cm^3 .

22. A glass substrate for an information recording medium, which is made of the glass for an information recording medium substrate as defined in any one of Claims 1 to 21.

5 23. The glass substrate for an information recording medium according to Claim 22, wherein when immersed in 0.01 N nitric acid at 25°C, the etching rate of glass is at most 0.3 nm/h.

24. The glass substrate for an information recording medium according to Claim 22 or 23, wherein when the glass is left under a steam atmosphere at 120°C at 0.2 MPa for 20 hours, $C_R = C_{Li} + C_{Na} + C_K$ is at most 12 nmol/cm², where C_{Li} , C_{Na} and C_K are the
10 amounts of Li, Na and K which precipitate on a surface of the glass, respectively.

25. A magnetic disk having a magnetic recording layer formed on the glass substrate for an information recording medium as defined in Claim 22, 23 or 24.